

**AMENDMENTS TO THE SPECIFICATION:**

*Please rewrite the paragraphs from page 8, line 5, to page 8, line 8, as follows:*

Fig. 8(a) and Fig. 8(b) are is-a-plan views for describing a method for forming a mask pattern according to the present invention; and

Fig. 9(a), Fig. 9(b), and Fig 9(c) are is-a-plan views for describing a method for exposure with light according to the present invention.